## In the Abstract:

Integrated semiconductor structure

The invention relates to a<u>A</u>n integrated semiconductor structure, having has a substrate (1), at least one a semiconductor element (2)-located on the substrate (1), a pad metal (3) having a surface (F), a multiplicity of metal layers (4.x) which are located between the pad metal (3) and the substrate (1), and a multiplicity of insulation layers (5.y), which that separate the metal layers (4.x) from one another, t. The pad metal (3) extendings at least over at least -part of the at least one semiconductor element (2).

The invention is distinguished by the fact that, b\_Below the surface (F) of the pad metal-(3), at least the top two metal layers (4.x, 4.x-1) have a structure which in each case at least-includes two or more adjacent interconnects (4.x.z, 4.x-1.z).